



#104A
12/15/02
PATENT

Customer No. 228524
Attorney Docket No. 04173.0403

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
Yutaka HASEGAWA et al.) Group Art Unit: 1764
Serial No.: 09/472,150) Examiner: J. Leung
Filed: December 27, 1999)
For: HIGH-PRESSURE TREATMENT)
APPARATUS, FEEDING METHOD)
THERE TO AND PROTECTION)
METHOD THEREOF)

Commissioner for Patents and Trademarks
Washington, DC 20231

Sir:

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AMENDMENT

In reply to the Office Action dated September 13, 2002 (Paper No. 9), please
amend the application as follows:

IN THE SPECIFICATION:

Please amend the specification as follows:

Please amend the paragraph on page 35, lines 17-23 as follows:

Within the high-pressure reactor 200 and gap 202, water is fed by a pump 211
through the duct 212. The pressure sensors 231 and 232 measure the pressures of the
waters. Based on the measured values, the pressure controller 215 maintains the
pressure of the water within the gap 202 higher than that of the inside of the high-
pressure reactor 200 by approximately 0.5 MPa to 5 MPa.

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